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Application Information

Title Line One:: METHOD AND APPARATUS FOR ION Title Line Two:: ATTACHMENT MASS SPECTROMETRY

Title Line Three:: Title Line Four::

Total Drawing Sheets::

Docket Number: 111522

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Patent Number::

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Yes

Prior Foreign Applications

JP 2000-401483 Foreign Application One:: December 28, 2000

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Priority Claimed:: Foreign Application Two::

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Priority Claimed::

Foreign Application Three::

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Priority Claimed::

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2